## **EAST Search History**

| Ref<br># | Hits   | Search Query                                       | DBs   | Default<br>Operator | Plurals | Time Stamp       |
|----------|--------|--|---|---------------------|---------|------------------|
| L1       | 84382  | "356"/\$.ccls.                                     | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:30 |
| L2       | 774    | 1 and index adj2 match\$3                          | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:28 |
| L3       | 246    | 2 and (uv or ultraviolet)                          | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:29 |
| L4       | 136    | 3 and (wafer or reticle or substrate)              | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:29 |
| L5       | 264    | 1 and (index adj2 match\$3 adj2 (fluid or liquid)) | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:30 |
| L6       | 89     | 5 and (uv or ultraviolet)                          | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:30 |
| L7       | 47     | 6 and (wafer or reticle or substrate)              | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:30 |
| L8       | 0      | 7 not 4  | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:30 |
| L9       | 114990 | "250"/\$.ccls.                                     | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR                  | ON      | 2006/03/08 07:30 |

## **EAST Search History**

| L10 | 140 | 9 and (index adj2 match\$3 adj2 (fluid or liquid)) | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2006/03/08 07:30 |
|-----|-----|--|---|----|-----|------------------|
| L11 | 59  | 10 and (uv or ultraviolet)                         | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2006/03/08 07:30 |
| L12 | 53  | 11 not 4   | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2006/03/08 07:30 |
| L13 | 20  | 12 and (wafer or reticle or substrate)             | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2006/03/08 07:30 |
| S1  | 2   | ("5696591").PN.                                    | US-PGPUB;<br>USPAT;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/05/17 07:07 |

PLUS Search Results for S/N 10725744, Searched March 08, 2006

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